	Hits	Search Text	DBs
24	4	(zone near9 plate) same (substrate or wafer or workpiece) same (HSQ or (e$2beam near6 resist) or silsesquioxane)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
25	16	((substrate or wafer or workpiece) same (HSQ or (e$2beam near6 resist) or silsesquioxane)) and (zone near9 plate)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB
26	17	((substrate or wafer or workpiece) same (HSQ or (e$2beam near6 resist) or silsesquioxane or resist)) and ((DOE or (diffractive near12 element) or (zone near9 plate)) same apodiz$6)	US-PGPUB; USPAT; FPRS; EPO; JPO; DERWENT; IBM_TDB